## CASE HISTORY

**Pulp and Paper** 



## RECORDED BENEFITS

- 12% decrease in program cost
- FPAR in high 60's with drainage to spare.
- OME >99%. Only 5 sheet breaks in first month of application.
- Flexible program
  capable of addressing
  future program needs higher sheet ash,
  increased machine
  speeds, etc.

# MicroSol<sup>SM</sup> Reduces Cost and Improves

## MicroSol<sup>SM</sup> Advanced Retention and Drainage

## **Customer Challenge**

A Southern U.S. uncoated freesheet producer was interested in reducing costs and asked Solenis to review their retention and drainage program. The targeted machine is a 1050 TPD horizontal gap former producing offset grades. The incumbent program was structured silica, anionic polyacrylamide, and PAC providing adequate retention and drainage performance.

### **Recommended Solution**

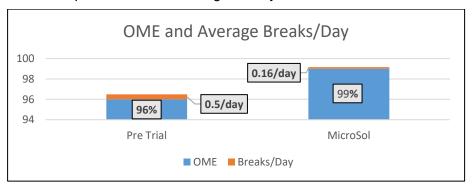
After a wet end audit, along with the appropriate lab testing, Solenis recommended a MicroSol Advanced Retention and Drainage program that included:

- PerForm™ MP9031 structured silica
- PerForm™ SP7202 structured polymer
- PerForm™ PA8147 anionic polyacrylamide

These program components were all fed post-screen through four Solenis Vmax™ injection nozzles. PAC was also split fed to the machine chest and fan pump.

### **Results Achieved**

Results were excellent. PerForm SP7202 was set in ratio control with PerForm PA8147 and controlled by a Kajaani with a target tray consistency of 0.115%. Transition to the Solenis MicroSol program was seamless and all performance metrics and sheet quality targets were met on the first reel. The program delivered a 12% reduction in cost while increasing OME from 96% to 99.1%. The MicroSol program also provides unique flexibility for change. If the customer needs to increase machine speed or sheet ash targets, they can utilize MicroSol.



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